

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	2	etch\$3 same Si2F6	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 11:03			0
2	BRS	L7	3	etch\$3 and Si2F6	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 10:26			0
3	BRS	L13	2	etching and Si2F6	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 10:27			0
4	BRS	L19	34	(Si or silicon) and Si2F6	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 10:27			0
5	BRS	L25	0	etchant same Si2F6	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 11:04			0
6	BRS	L31	1	etchant and Si2F6	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 11:10			0
7	BRS	L43	3	etch\$3t same (Si2F6 or "silicon hexafluoride")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 11:11			0
8	BRS	L37	11	etch\$3t and (Si2F6 or "silicon hexafluoride")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 11:15			0
9	BRS	L49	1	etch\$3t and (Si2F6 or "disilicon hexafluoride")	USPAT; EPO; JPO; DERWENT; IBM TDB	2001/10/04 11:16			0